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BRS	BRS	BRS	IS&R 8	BRS	BRS	BRS	Туре
Θ	9	119	8	3	15	394	Hits
S6 and (trench and via)	S5 and (porous adj dielectric)	S1 and (hard adj mask)	(("6479391") or ("6514852") or ("6573176") or ("6576482")).PN.	S2 and (reactive adj ion adj etching)	S1 and (porous adj dielectric)	438/638 and (dual adj damascene adj process)	Search Text
US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; 17:21 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; 16:43 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/20 DERWENT; 16:42 IBM_TDB	DBs
2004/11/20 17:21	2004/11/20 17:20	2004/11/20 17:14	2004/11/20 17:14	2004/11/20 17:10	2004/11/20 16:43	2004/11/20 16:42	Time Stamp
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BRS	BRS	BRS	BRS	BRS	BRS	BRS	Туре
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S12 and (three adj hard adj masks)	S12 and (triple adj hard adj masks)	S8 and (hard adj masks)	S8 and (hardmsks)	S8 and (three adj hardmsks)	S8 and (triple adj hardmasks)	438/638 and (dual adj damascene adj process)	Search Text
US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:50 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:49 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:47 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:45 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:45 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:44 IBM_TDB	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; IBM_TDB	DBs
2004/11/22 13:50	2004/11/22 13:49	2004/11/22 13:47	2004/11/22 13:45	2004/11/22 13:45	2004/11/22 13:44	2004/11/22 13:44	Time Stamp
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14	13	12	11	10	9	∞	
S14	S13	S12	S11	S10	S9	S8	Ref#

	Туре	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
15	BRS	15	S8 and (porous adj dielectric)	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 13:51 IBM_TDB	2004/11/22 13:51			
16	BRS	9	S15 and (hard adj masks)	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 14:50 IBM_TDB	2004/11/22 14:50			
17	BRS	147	S8 and (low adj k adj dielectric)	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; IBM_TDB	2004/11/22 14:51			
18	BRS	55	S17 and (hard adj masks)	US-PGPUB; USPAT; EPO; JPO; 2004/11/22 DERWENT; 14:52 IBM_TDB	2004/11/22 14:52			

18	17	16	15	
S18	S17	S16	S15	Ref#